

L Number	Hits	Search Text	DB	Time stamp
3	13	("4655594"   "5040431"   "5528118"   "5610686"   "5623853"   "5699621"   "5760564"   "5858587"   "5864389"   "5909272"   "5939852"   "6028376"   "6038013").PN.	USPAT	2003/04/11 11:55
4	9	("4698575"   "4869481"   "5040431"   "5184055"   "5280677"   "5376988"   "5382095"   "5440397"   "5671058").PN.	USPAT	2003/04/11 12:02
5	7359	355/53-74.ccls.	USPAT; US-PGPUB	2003/04/11 12:09
6	17	355/53-74.ccls. and (hold\$3 adj3 rotate)	USPAT; US-PGPUB	2003/04/11 12:12
7	1819	355/53-74.ccls. and wafer	USPAT; US-PGPUB	2003/04/11 12:12
8	24	355/53-74.ccls. and (rotate adj3 wafer)	USPAT; US-PGPUB	2003/04/11 12:12
9	24	(355/53-74.ccls. and (rotate adj3 wafer)) not (355/53-74.ccls. and (hold\$3 adj3 rotate))	USPAT; US-PGPUB	2003/04/11 12:28
10	19	("3541338"   "4758863"   "4841341"   "4905041"   "5160957"   "5476736"   "5498501"   "5539497"   "5673103"   "5726741"   "5849437"   "5854671"   "5883700"   "5933219"   "5995200"   "6020092"   "6074787"   "6078381"   "6090527").PN.	USPAT	2003/04/11 12:14
11	486	wafer and (rotat\$3 adj3 ("180" adj2 degrees))	USPAT; US-PGPUB	2003/04/11 12:30
12	0	((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and (rotat\$3 adj3 ("25" adj2 degrees)))	USPAT; US-PGPUB	2003/04/11 12:30
13	245	((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor	USPAT; US-PGPUB	2003/04/11 12:31
14	166	((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage	USPAT; US-PGPUB	2003/04/11 12:31
15	5	((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage) and damper	USPAT; US-PGPUB	2003/04/11 12:33
16	84	((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage) and vibration	USPAT; US-PGPUB	2003/04/11 12:33
17	82	((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage) and vibration) not (((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage) and damper)	USPAT; US-PGPUB	2003/04/11 12:36
18	84	((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage) not (((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage) and vibration) not (((wafer and (rotat\$3 adj3 ("180" adj2 degrees))) and motor) and stage) and damper)	USPAT; US-PGPUB	2003/04/11 12:40
19	46983	318/\$.ccls.	USPAT; US-PGPUB	2003/04/11 12:41
20	321	318/\$.ccls. and wafer	USPAT; US-PGPUB	2003/04/11 12:41
21	38	318/\$.ccls. and (rotat\$3 adj2 wafer)	USPAT; US-PGPUB	2003/04/11 12:43
22	14068	(exposure adj2 (apparatus device))	USPAT; US-PGPUB	2003/04/11 12:44
23	368	((exposure adj2 (apparatus device))) and (wafer adj3 rotat\$3)	USPAT; US-PGPUB	2003/04/11 12:45
24	44	((exposure adj2 (apparatus device))) and (wafer adj3 rotat\$3) and gravity	USPAT; US-PGPUB	2003/04/11 12:45
25	31	((exposure adj2 (apparatus device))) and (wafer adj3 rotat\$3) and (stage adj3 motor)	USPAT; US-PGPUB	2003/04/11 12:45

26	115	((exposure adj2 (apparatus device))) and (wafer adj3 rotat\$3)) and (damp\$3 vibration)	USPAT; US-PGPUB	2003/04/11 12:46
27	140	((exposure adj2 (apparatus device))) and (wafer adj3 rotat\$3)) and gravity) (((exposure adj2 (apparatus device))) and (wafer adj3 rotat\$3)) and (stage adj3 motor)) (((exposure adj2 (apparatus device))) and (wafer adj3 rotat\$3)) and (damp\$3 vibration))	USPAT; US-PGPUB	2003/04/11 12:58
28	7	("6486941") or ("4698575") or ("6522389") or ("4910549") or ("5641264") or ("4887904") or ("4775877")).PN.	USPAT; US-PGPUB	2003/04/11 12:58
-	365	(wafer adj3 holder) same rotate	USPAT; US-PGPUB	2003/04/09 14:47
-	105	((wafer adj3 holder) same rotate) and exposure	USPAT; US-PGPUB	2003/04/09 14:47
-	62	((wafer adj3 holder) same rotate) and exposure) and motor	USPAT; US-PGPUB	2003/04/09 14:50
-	62284	(semiconductor wafer) same (rotat\$4 turn\$4)	USPAT; US-PGPUB	2003/04/09 14:52
-	27925	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)	USPAT; US-PGPUB	2003/04/09 14:58
-	2070	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))	USPAT; US-PGPUB	2003/04/09 14:59
-	992	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor	USPAT; US-PGPUB	2003/04/09 14:59
-	0	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and ("25" adj2 degrees)	USPAT; US-PGPUB	2003/04/09 15:00
-	59	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (wafer adj2 stop\$3)	USPAT; US-PGPUB	2003/04/09 15:00
-	352	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (355/\$.ccls.)	USPAT; US-PGPUB	2003/04/09 15:00
-	40	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (318/\$.ccls.)	USPAT; US-PGPUB	2003/04/09 15:01
-	415	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (wafer adj2 stop\$3)) (((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (355/\$.ccls.)	USPAT; US-PGPUB	2003/04/09 15:01
-	63	((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (wafer adj2 stop\$3)) (((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (355/\$.ccls.)	USPAT; US-PGPUB	2003/04/09 15:09
-		((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (318/\$.ccls.)) and (damp\$4)		

-	9	("4989031"   "5473410"   "5528118"   "5559584"   "5909272"   "5982128"   "6087797"   "6252314"   "6271606").PN.	USPAT	2003/04/09 15:03
-	12	("3940676"   "5153494"   "5204712"   "5260580"   "5467720"   "5518550"   "5528118"   "5610686"   "5684856"   "5773951"   "5841250"   "5909272").PN.	USPAT	2003/04/09 15:05
-	15	(((((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (wafer adj2 stop\$3)) (((((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (355/\$.ccls.)) (((((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (318/\$.ccls.))) and (damp\$4)) and (((((semiconductor wafer) same (rotat\$4 turn\$4)) and (stage table)) and (exposure adj2 (apparatus system device))) and motor) and (wafer adj2 stop\$3))	USPAT; US-PGPUB	2003/04/09 15:13
-	46978	318/\$.ccls.	USPAT; US-PGPUB	2003/04/09 15:13
-	321	318/\$.ccls. and wafer	USPAT; US-PGPUB	2003/04/09 15:13
-	58	(318/\$.ccls. and wafer) and damp\$3	USPAT; US-PGPUB	2003/04/09 15:14
-	107	318/\$.ccls. and (moving adj2 stage)	USPAT; US-PGPUB	2003/04/09 15:15
-	98	(318/\$.ccls. and (moving adj2 stage)) and motor	USPAT; US-PGPUB	2003/04/09 15:15
-	25	((318/\$.ccls. and (moving adj2 stage)) and motor) and damp\$3	USPAT; US-PGPUB	2003/04/09 15:19
-	41	(318/\$.ccls. and wafer) and (rotat\$3 adj3 (wafer (semiconductor adj2 device)))	USPAT; US-PGPUB	2003/04/09 15:26
-	41	((318/\$.ccls. and wafer) and (rotat\$3 adj3 (wafer (semiconductor adj2 device)))) not ((318/\$.ccls. and (moving adj2 stage)) and motor) and damp\$3)	USPAT; US-PGPUB	2003/04/09 15:32
-	7	("5959427") or ("6304320") or ("6373153") or ("6486941") or ("6437463") or ("6316901") or ("6355994").PN.	USPAT; US-PGPUB	2003/04/11 12:09